

# Manzar Siddik

## List of Publications by Year in descending order

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16  
papers

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#	ARTICLE	IF	CITATIONS
1	Low temperature solution-processed graphene oxide/Pr <sub>0.7</sub> Ca <sub>0.3</sub> MnO <sub>3</sub> based resistive-memory device. Applied Physics Letters, 2011, 99, .	3.3	42
2	Highly uniform and reliable resistance switching properties in bilayer WO <sub>x</sub> /NbO <sub>x</sub> RRAM devices. Physica Status Solidi (A) Applications and Materials Science, 2012, 209, 1179-1183.	1.8	37
3	Noise-Analysis-Based Model of Filamentary Switching ReRAM With $\text{ZrO}_x/\text{HfO}_x$ Stacks. IEEE Electron Device Letters, 2011, 32, 964-966.	3.9	33
4	Self-formed Schottky barrier induced selectorless RRAM for crosspoint memory applications. Physica Status Solidi - Rapid Research Letters, 2012, 6, 454-456.	2.4	31
5	Excellent resistive switching in nitrogen-doped Ge <sub>2</sub> Sb <sub>2</sub> Te <sub>5</sub> devices for field-programmable gate array configurations. Applied Physics Letters, 2011, 99, 192110.	3.3	21
6	Memristive switching behavior in Pr <sub>0.7</sub> Ca <sub>0.3</sub> MnO <sub>3</sub> by incorporating an oxygen-deficient layer. Physica Status Solidi - Rapid Research Letters, 2011, 5, 409-411.	2.4	19
7	Modeling of Breakdown-Limited Endurance in Spin-Transfer Torque Magnetic Memory Under Pulsed Cycling Regime. IEEE Transactions on Electron Devices, 2018, 65, 2470-2478.	3.0	19
8	Random Number Generation by Differential Read of Stochastic Switching in Spin-Transfer Torque Memory. IEEE Electron Device Letters, 2018, 39, 951-954.	3.9	19
9	Effect of interfacial oxide layer on the switching uniformity of Ge <sub>2</sub> Sb <sub>2</sub> Te <sub>5</sub> -based resistive change memory devices. Applied Physics Letters, 2011, 99, 162109.	3.3	15
10	Operation Voltage Control in Complementary Resistive Switches Using Heterodevice. IEEE Electron Device Letters, 2012, 33, 600-602.	3.9	15
11	Thermally assisted resistive switching in Pr <sub>0.7</sub> Ca <sub>0.3</sub> MnO <sub>3</sub> /Ti/Ge <sub>2</sub> Sb <sub>2</sub> Te <sub>5</sub> stack for nonvolatile memory applications. Applied Physics Letters, 2011, 99, .	3.3	14
12	Effect of $\text{Ge}_2\text{Sb}_2\text{Te}_5$ Thermal Barrier on Reset Operations in Filament-Type Resistive Memory. IEEE Electron Device Letters, 2011, 32, 1573-1575.	3.9	13
13	A nitrogen-treated memristive device for tunable electronic synapses. Semiconductor Science and Technology, 2014, 29, 104006.	2.0	10
14	A Physics-Based Compact Model of Stochastic Switching in Spin-Transfer Torque Magnetic Memory. IEEE Transactions on Electron Devices, 2019, 66, 4176-4182.	3.0	10
15	Thermally-assisted Ti/Pr<sub>0.7</sub>Ca<sub>0.3</sub>MnO<sub>3</sub> ReRAM with excellent switching speed and retention characteristics. , 2011, , .		5
16	Improved switching characteristics of perovskite oxide-based resistance random access memory by high-pressure oxygen annealing at low temperature. Physica Status Solidi (A) Applications and Materials Science, 2011, 208, 202-205.	1.8	5